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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/031,787	05/20/2002	Claudia Wiegand	MERCK 2341	5718	
23599	7590 03/30/2006			EXAMINER	
MILLEN, WHITE, ZELANO & BRANIGAN, P.C.			OLSEN, ALLAN W		
2200 CLARE SUITE 1400	ENDON BLVD.		ART UNIT	PAPER NUMBER	
ARLINGTON, VA 22201			1763		
			DATE MAIL ED: 02/20/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/031,787	WIEGAND ET AL.				
Office Action Summary	Examiner	Art Unit				
	Allan Olsen	1763				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl if NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be timely within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 10 J	anuary 2006.					
· <u> </u>	<i>,</i> —					
closed in accordance with the practice under E	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
 4a) Of the above claim(s) <u>8-13 and 20-26</u> is/are 5) ☐ Claim(s) is/are allowed. 6) ☒ Claim(s) <u>4,5,7,14 and 17-19</u> is/are rejected. 7) ☐ Claim(s) is/are objected to. 	⊠ Claim(s) <u>4,5,7,14 and 17-19</u> is/are rejected.					
Application Papers						
9)⊠ The specification is objected to by the Examine 10)⊠ The drawing(s) filed on 11 March 2003 is/are: Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11)□ The oath or declaration is objected to by the Example 11.	a) \square accepted or b) \square objected to drawing(s) be held in abeyance. See tion is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
Attachment(s)						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail Da					

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DETAILED ACTION

Specification

The disclosure is objected to because of the following informalities:

On page 3, line 35, "BBSG" should read --BPSG--.

Appropriate correction is required.

Election/Restrictions

Newly submitted claims 20-26 are directed to an invention that is independent or distinct from the invention originally claimed for the following reasons: New claims 20-26 and the examined group of claims, (i.e., claim 17 and claims dependent thereon) are related as combination and subcombination. Inventions in this relationship are distinct if it can be shown that (1) the combination as claimed does not require the particulars of the subcombination as claimed for patentability, and (2) that the subcombination has utility by itself or in other combinations (MPEP § 806.05(c)). In the instant case, the combination (claims 20-26) as claimed does not require the particulars of the subcombination as claimed because the combination does not require that the composition has the property of etching the doped oxide BSG at a much higher rate than it etches thermal oxide, thus being capable of essentially not etching thermal oxide while etching said doped oxide. The subcombination has separate utility such as serving as the etchant in a process that etches silicon oxide from a substrate that is void of a doped silicate layer.

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Since applicant has received an action on the merits for the originally presented invention, this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, claims 20-26 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

Claim Rejections - 35 USC § 112

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 18 and 19 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement.

The claims contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventors, at the time the application was filed, had possession of the claimed invention. The specification teaches a hydrofluoric acid content of 5-20%, however, there does not appear to be support for a composition comprising either 10 % or 15 % HF in combination with a solvent mixture consisting essentially of at least two of ethylene glycol, propylene glycol, ethanol, and glycerol.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 4, 5, 7, 14 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Deckert.

Deckert teaches HF/glycerol and HF/ethylene glycol compositions. Deckert teaches preparing an etching solution by adding 100 mL of concentrated HF (49% HF by weight) to glycerol to make 1 liter of solution. Deckert teaches that this solution is 3M in HF. Therefore, the 1 L of solution contains 3 moles of HF, which is about 60 grams of HF. Because a 49% HF solution has a density of 1.19 g/mL, the 100 mL of concentrated HF that Deckert adds to glycerol contributes 119 grams to the total mass of the solution. The balance of the solution is \sim 900 mL of glycerol which, given its density of 1.26 g/mL, would have a mass of about 1134 grams. These numbers (e.g., 60 g HF /(119 +1134) \approx 5%) provide for HF and H2O concentrations that correspond to the claimed ranges.

Deckert does not teach mixing ethylene glycol and glycerol with a ratio of 1:5 to 5:1.

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It would have been obvious for one skilled in the art to make the etching solution of Deckert with a 1:1 mixture of glycerol and ethylene glycol because "[i]t is prima facie obvious to combine two compositions each of which is taught by the prior art to be useful for the same purpose, in order to form a third composition which is to be used for the very same purpose."

Deckert does not teach using high purity components in the etching mixture.

It would be obvious to use high purity components so that the etching solution is not a source of contamination.

While Deckert does not teach that the etches doped oxide BSG at a much higher rate than it etches thermal oxide, and that the solution is capable of essentially not etching thermal oxide while etching said doped oxide, these features are considered inherent in the composition made obvious by Deckert.

Claims 18 and 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Deckert in view of US Patent 5,767,020 issued to Sakaguchi et al. (hereinafter, Sakaguchi).

The above noted teachings of Deckert are herein relied upon. Additionally, it is noted Deckert teaches that the concentration of the etching composition is not critical, and Deckert adds, in general a more concentrated solution provides a faster etch rates (column 3, lines 22-25). Furthermore, Deckert teaches that a criterion for selecting the

In re Kerkhoven 205 USPQ 1069 (CCPA 1980). Cites In re Susi 169 USPQ 423, 426 (CCPA 1971); In re Crockett 126 USPQ 186, 188 (CCPA 1960). See also Ex parte Quadranti 25 USPQ 2d 1071 (BPAI 1992).

organic component of the etchant is that the organic component must be compatible with the HF and water (column 3, lines 13-18).

Deckert does not teach a composition comprising 10-20% HF.

Sakaguchi teaches an etching composition comprising a mixture of 5-95% HF and an alcohol.

It would have been obvious for one skilled in the art to increase the HF concentration to 15-20% HF because Deckert teaches that high concentrations provide higher etching rates and Sakaguchi demonstrates that alcohols are compatible with very high HF concentrations.

Response to Arguments

Applicant's arguments have been fully considered but they are not persuasive.

With respect to Deckert, Applicant argues, that the composition of Deckert and applicant's claimed composition have different intended uses. Deckert's composition is for etching oxide and nitride whereas "Applicant's solution is for etching layers of BSG, BPSG, PSG and <u>not</u> thermal oxide. Thus Deckert cannot motivate any changes directed to such an etching application."

The examiner notes applicant's claims are directed to a composition, not to a method of etching any particular type of oxide. The intended use of applicant's composition is not relevant to the patentability of the composition.

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Applicant argues that Sakaguchi is irrelevant because it does not teach solvent mixtures and therefore does not cure the deficiency of Deckert.

The examiner disagrees because Deckert teaches: 1) the concentration of the etching composition is not critical; 2) a more concentrated solution provides a faster etch rates (column 3, lines 22-25); and 3) the organic component of the etchant must be compatible with the HF. As such, Sakaguchi is not irrelevant because Sakaguchi teaches that the alcohols used by Deckert are compatible with HF concentrations of up to 95%.

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Allan Olsen whose telephone number is 571-272-1441. The examiner can normally be reached on M-F 1-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Alla Olsa

Allan Olsen Primary Examiner

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